

Freeform Search

Database: US Patents Full-Text Database
US Pre-Grant Publication Full-Text Database
JPO Abstracts Database
EPO Abstracts Database
Derwent World Patents Index
IBM Technical Disclosure Bulletins

Term: L3 and @pd<20000927

Display: 25 Documents in Display Format: - Starting with Number 1

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result set

DB=USPT,PGPB; PLUR=YES; OP=ADJ

<u>L5</u>	5403438[uref]	1	<u>L5</u>
<u>L4</u>	L3 and @pd<20000927	163	<u>L4</u>
<u>L3</u>	L2 and ((coat\$3 or cover\$3) near5 resist)	287	<u>L3</u>
<u>L2</u>	L1 same (pattern\$3 near5 first resist)	434	<u>L2</u>
<u>L1</u>	resist same pattern\$3	36779	<u>L1</u>

END OF SEARCH HISTORY

L Number	Hits	Search Text	DB	Time stamp
1	3793	(resist near pattern) same cover\$3	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/30 15:38
2	194	((resist near pattern) same cover\$3) same (second near resist)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/30 15:39
3	130	((((resist near pattern) same cover\$3) same (second near resist)) and @pd<20000927	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/30 15:42
-	105769	resist same (pattern\$3 or etch\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/30 15:36
-	2698	(resist same (pattern\$3 or etch\$3)) same (second near resist)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/30 12:03
-	933	((resist same (pattern\$3 or etch\$3)) same (second near resist)) same (coat\$3 or cover\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/30 13:06
-	645	((((resist same (pattern\$3 or etch\$3)) same (second near resist)) same (coat\$3 or cover\$3)) and @pd<20000927	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/30 13:11
-	15	(((((resist same (pattern\$3 or etch\$3)) same (second near resist)) same (coat\$3 or cover\$3)) and @pd<20000927) and ((polysilesesquioxane or "SOG") same etch\$3)	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/30 12:09
-	193	((resist same (pattern\$3 or etch\$3)) same (second near resist)) same ((coat\$3 or cover\$3) same (polysilesesquioxane or "SOG" or metal))	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/30 13:08
-	133	((((resist same (pattern\$3 or etch\$3)) same (second near resist)) same ((coat\$3 or cover\$3) same (polysilesesquioxane or "SOG" or metal))) and @pd<20000927	USPAT; US-PGPUB; EPO; JPO; DERWENT; IBM_TDB	2003/01/30 13:12